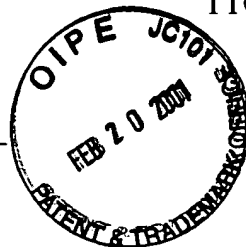


1763

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PATENT  
Attorney Docket No.: AM2119/T21300  
TTC Ref. No.: 16301M-021300US

Assistant Commissioner for Patents  
Washington, D.C. 20231



On February 15, 2001

TOWNSEND and TOWNSEND and CREW LLP

By: 

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Karl Littau et al.

Application No.: 08/893,917

Filed: July 11, 1997

For: REMOTE PLASMA CLEANING  
SOURCE HAVING REDUCED  
REACTIVITY WITH A SUBSTRATE  
PROCESSING CHAMBER

Examiner: Rudy Zervigon

Art Unit: 1763

PETITION TO EXTEND TIME

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Assistant Commissioner for Patents  
Washington, D.C. 20231

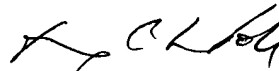
Sir:

Applicants petition the Assistant Commissioner of Patents to extend the time for response to the Appellant's Reply Brief Under 37 C.F.R. § 1.193(b)(1) dated December 8, 2000 for 1 month, from February 8, 2001 to March 8, 2001. An appropriate response in the form of a Response to Appellant's Reply Brief Under 37 C.F.R. 1.193(b)(1) is enclosed herewith.

Please charge the fee of \$110.00 to the undersigned's Deposit Account No. 20-1430.

Please charge any additional fees or credit overpayment to the above deposit account..

Respectfully submitted,



Chun-Pok Leung  
Reg. No. 41,405

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